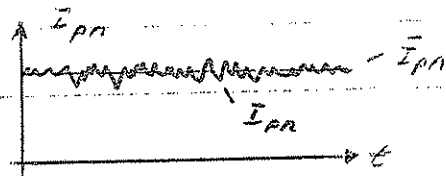


VIII Noise in Integrated Circuits

1. Sources of Noise

A) Shot Noise

1. Causes Carriers must jump potential barrier between a p-n junction (Random process). Hence, the effective current flowing through the junction fluctuates around its average value in a random way.



2. Spectral density:

$$\begin{aligned} \overline{i^2} &= \lim_{T \rightarrow \infty} \frac{1}{T} \int_0^T (\bar{I}_{pn} - \bar{I}_{pn})^2 dt \\ &= \underline{2q \bar{I}_{pn} \Delta f} \quad f < \frac{1}{\tau} \end{aligned}$$

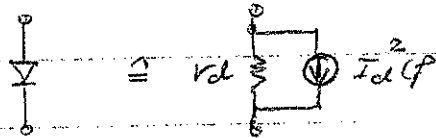
q : electron charge

c.f. Noise

τ : Transit time of carrier

$\bar{I}_{pn}$: average current

of Bandwidth in Hz



$$r_d \approx \frac{h\nu}{q I_D} \quad I_d^2(f) \approx 2q I_D$$

$\Rightarrow$ Frequency distribution: White

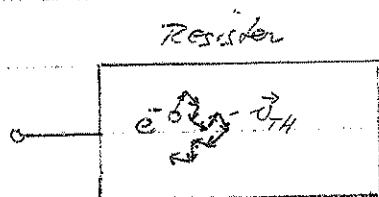
Amplitude variation: Gaussian ($\overline{i^2} = \sigma^2$)

i.e. noise signal is $\pm 3\sigma$ in 99.7% of time

B) Thermal Noise

1. Causes Random Thermal Motion of Electrons in any conductor

Notes: Since $v_{\text{drift}} \ll v_{\text{TH}}$ Thermal noise is independent of current but proportional to T



$$v_{\text{TH}} = \sqrt{\frac{3kT}{m_e}}$$

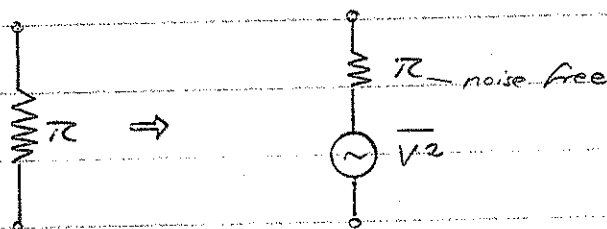
effective mass of e^- in crystal lattice

e.g. $T = 300^\circ\text{K}$

$$v_{\text{TH}} \approx 10^5 \frac{\text{m}}{\text{s}}$$

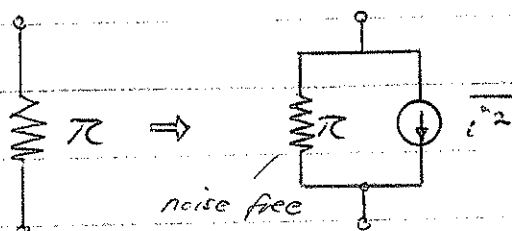
2. Spectral Density

represented by a voltage source



$$\overline{V^2} = 4kTR\Delta f$$

represented by a current source



$$\overline{i^2} = \frac{4kT}{R} \Delta f$$

$\Rightarrow$ Frequency distribution: White

Amplitude variations: Gaussian ($\overline{i^2} = \sigma^2 / \overline{V^2} = \sigma^2$)

C) Flicker Noise ($1/f$ Noise)

1. Cause: Traps in a material capture and emit
carriers in a Random Fashion

2. Spectral Density:

Empirical
$$\overline{i^2} = K_1 \frac{I^a}{f^b} \Delta f$$

I : direct current

MOSFET

K_1 : Constant

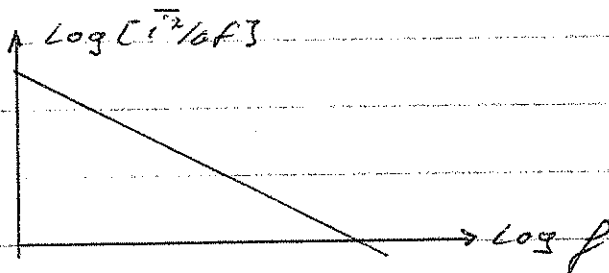
$$V_{th}^2 \approx \frac{kV}{WLCox} \frac{1}{f} \Delta f$$

$a \approx 0.5$ to 2

$b \approx 1$

The time constants associated with the capture and release of charge carriers give rise to a noise signal with energy concentrated at low frequencies.

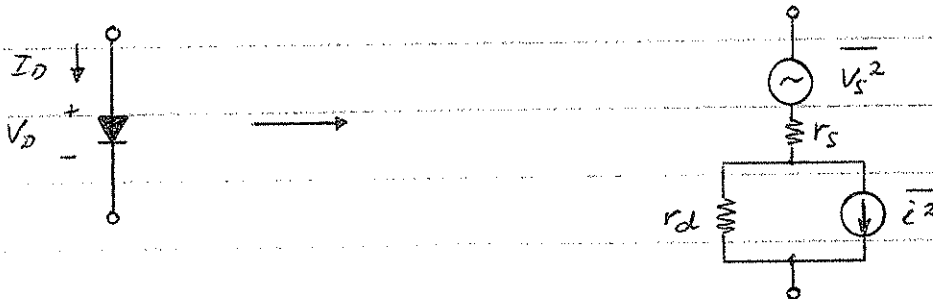
Frequency distribution



Amplitude variations Often Not Gaussian

2. Noise Models for IC Components

A) Junction Diode



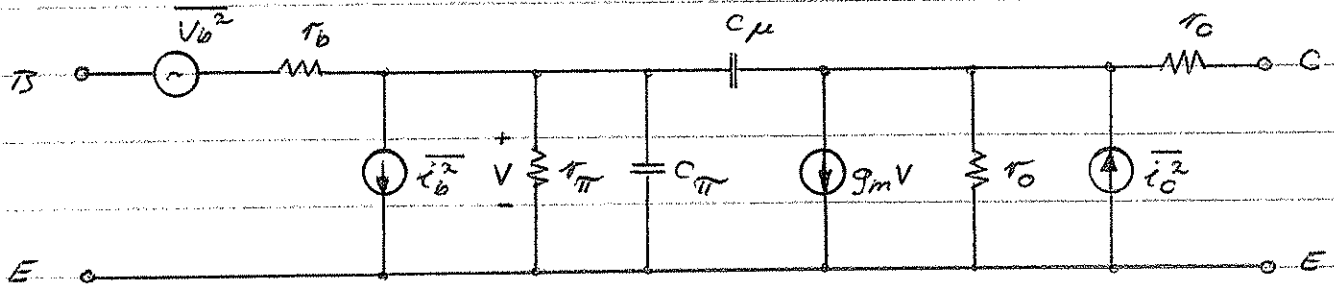
1. $r_d = \left[\frac{dI_D}{dV_D} \right]^{-1} = \frac{kT}{qI_D}$ Modelling resistor (produces no noise)

2. r_s physical series resistor (produces noise)

3. $\overline{V_s^2} = 4kT r_s \Delta f$: Thermal noise due to r_s

4. $\overline{i^2} = \underbrace{2qI_D \Delta f}_{\text{shot}} + \underbrace{k \frac{I_D}{f} \Delta f}_{\text{flicker}}$ shot noise and flicker noise of pn junction and semicond. material

13) Bipolar Transistor



1. $\overline{V_b^2} = 4kT r_b \Delta f$ due to base series resistor r_b (Thermal)

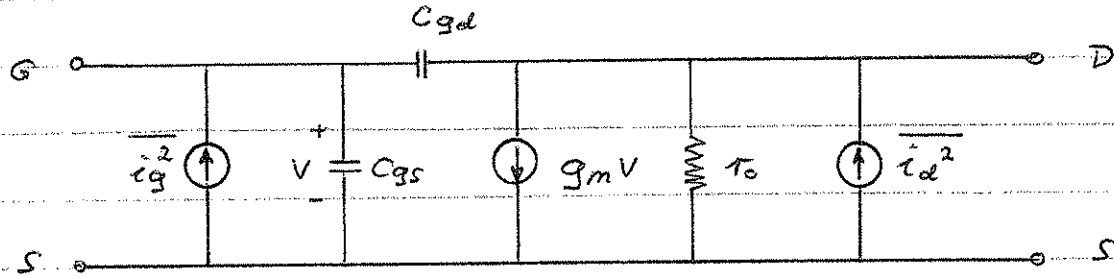
2. $\overline{i_b^2} = 2q \bar{i}_B \Delta f + k \frac{\bar{i}_B}{p} \Delta f$ Holes jumping into Emitter (shot)
Flicker Recombination current in Base (shot)

3. $\overline{i_c^2} = 2q \bar{i}_C \Delta f$ EL jumping from Emitter (shot)
Recomb. current in Base (shot)

4. Neglect Noise source associated with r_c (small)

Note: if recombination current in Base is small, then all Noise sources are statistically independent.

C) Field Effect Transistor



1. $\overline{i_g^2} = 2qI_G \Delta f$ Shot Noise due to reverse leakage in JFET

Note: $\overline{i_g^2} = 0$ for MOSFET

2. $\overline{i_d^2} = 4kT \left(\frac{1}{r_{CH}} \right) \Delta f + k_1 \frac{I_D^2}{P} \Delta f$

Thermal Noise

Flicker Noise

channel resistance r_{CH} :

Recall: $Q_T = \frac{2}{3} C_{ox} W \cdot L (V_{GS} - V_T)$

Total charge

$\frac{1}{r_{CH}} = \mu q \int_0^{x_j} n dx$
 $\underbrace{\int_0^{x_j} n dx}_{Q_T / WL}$

sheet resistance

$\Rightarrow \frac{1}{r_{CH}} = \frac{2}{3} \mu C_{ox} (V_{GS} - V_T)$

$r_{CH} = \frac{L}{W} \quad \bar{r}_S = \frac{L}{\frac{2}{3} \mu C_{ox} W (V_{GS} - V_T)}$

since $g_m = \mu C_{ox} \frac{W}{L} (V_{GS} - V_T)$

$\Rightarrow \underline{\underline{r_{CH} = \frac{1}{\frac{2}{3} g_m}}}$

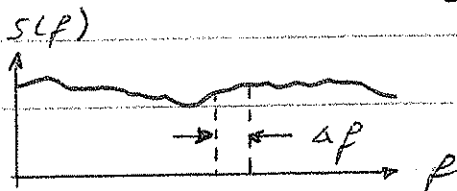
$\Rightarrow \overline{i_d^2} = 4kT \frac{2}{3} g_m \Delta f + k_1 \frac{I_D^2}{P} \Delta f$

MOSFET $\left| \overline{i_d^2} = 4kT \frac{2}{3} g_m \Delta f + \frac{h f g_m^2}{W L C_{ox} f} \right|$

3. Circuit Noise Calculations

Given: Noise current source with spectral density

$$S(f) = \frac{\bar{i}^2}{\Delta f}$$



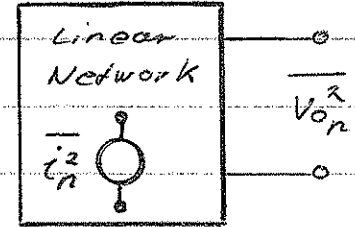
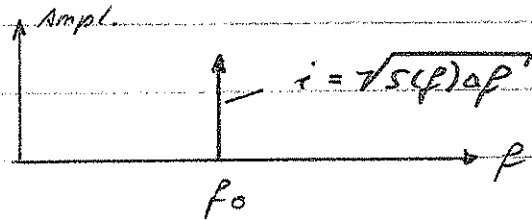
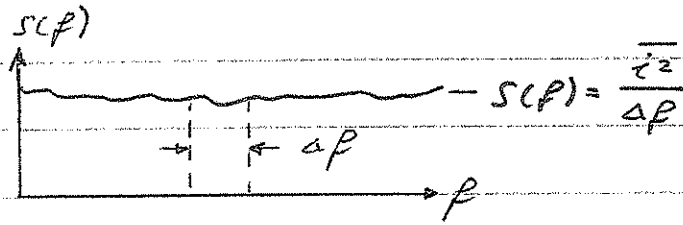
In a small bandwidth Δf , the mean-square value of the noise current is given by

$$i = \sqrt{S(f) \Delta f}$$

Thus, the noise current in bandwidth Δf can be represented approximately by a sinusoidal current generator with rms value i as shown above.

If the noise current in bandwidth Δf is now applied as an input signal to a circuit, its effect can be calculated by substituting the sinusoidal generator and performing circuit analysis in the usual fashion.

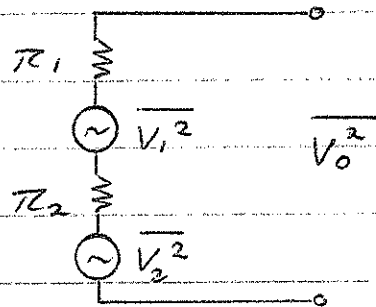
Thus network noise calculations reduce to familiar sinusoidal circuit analysis calculations.



Procedure:

1. Replace i_n^2 (V_n^2) with sinusoidal source of magnitude i_n (V_n) and frequency f_0
2. Calculate $V_{0n}(f_0)$ due to $i_n(f_0)$
3. V_{0n}^2 is output Power Spectrum Density at f_0
4. If more than 1 source and sources independent then add sum of squares $V_0^2 = \sum_n V_{0n}^2$

Example



Find V_0^2

$$1. \overline{V_1^2} = 4kT\pi_1 \Delta f$$

$$\overline{V_2^2} = 4kT\pi_2 \Delta f$$

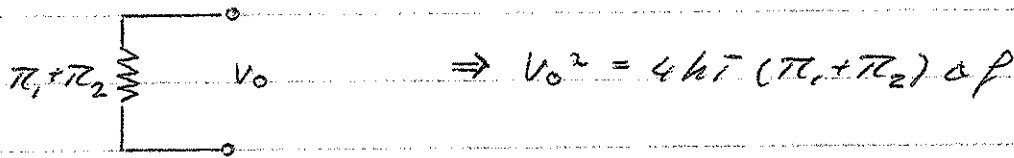
$$2. V_0 = V_1 + V_2 \Rightarrow \overline{V_0^2} = \overline{[V_1 + V_2]^2}$$

$$= \overline{V_1^2} + \overline{V_2^2} + 2 \overline{V_1 V_2}$$

Since V_1 is statistically independent of V_2
 $\overline{V_1 V_2} = 0$ (orthogonality)

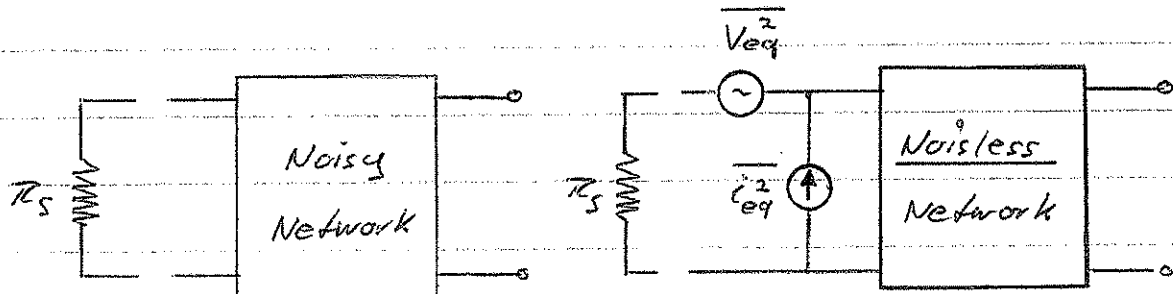
$$3. \underline{\underline{\overline{V_0^2} = \overline{V_1^2} + \overline{V_2^2} = 4kT(\pi_1 + \pi_2) \Delta f}}$$

$\Rightarrow$ equivalent network:



4. Equivalent Input Noise Generators

Idea: Replace noisy network by a noiseless network with equivalent input noise sources



1. If $R_S = 0$ $\overline{i_{eq}^2}$ is shorted
 $\overline{V_{eq}^2}$ is single noise source

2. If $R_S \rightarrow \infty$ $\overline{V_{eq}^2}$ is in open-loop
 $\overline{i_{eq}^2}$ is single noise source

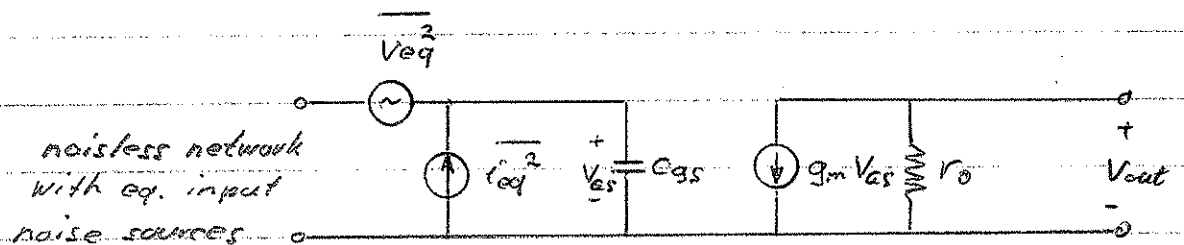
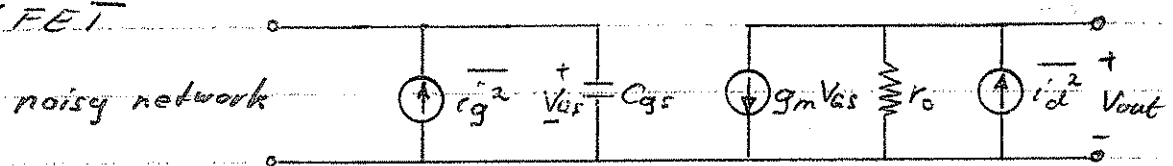
3. Finite R_S Both i_{eq} and V_{eq} contribute to output noise

How to find $\overline{V_{eq}^2}$ and $\overline{i_{eq}^2}$?

a) short input of both networks and equate output noise of both cases
Solve for $\overline{V_{eq}^2}$

b) Open input of both networks and equate output noise of both cases
Solve for $\overline{i_{eq}^2}$

Example ① JFET



A) Short inputs to find $\overline{v_{eq}^2}$

noisy NW

$$|V_{out} = i_d r_o|$$

noiseless NW

$$|V_{out} = -g_m v_{eq} r_o|$$

$$\therefore |i_d = -g_m v_{eq}|$$

$$\| \overline{v_{eq}^2} = \frac{\overline{i_d^2}}{g_m^2} = 4kT \frac{2}{3} g_m^{-1} af + k, \frac{I_D}{g_m^2} f af \|$$

B) Open inputs to find $\overline{i_{eq}^2}$

noisy NW

$$|V_{out} = (i_d - g_m \frac{i_f}{j\omega C_{gs}}) r_o|$$

noiseless NW

$$|V_{out} = -g_m \frac{i_{eq}}{j\omega C_{gs}} r_o|$$

$$\therefore |i_d - g_m \frac{i_f}{j\omega C_{gs}} = -g_m \frac{i_{eq}}{j\omega C_{gs}}|$$

$$|i_{eq} = i_f - \frac{j\omega C_{gs}}{g_m} i_d|$$

since i_f and i_d are statistically independent

$$\text{or } \overline{i_{eq}^2} = \overline{i_f^2} + \frac{\omega^2 C_{gs}^2}{g_m^2} \overline{i_d^2}$$

$$\| \overline{i_{eq}^2} = 2qI_D af + \omega^2 C_{gs}^2 \overline{v_{eq}^2} af \|$$

MOSFET $I_G \approx 0$

$$\overline{i_{eq}^2}_{MOS} \approx \omega^2 C_{gs}^2 \overline{v_{eq}^2} af$$

small at low to moderate frequencies

Comments:

1. V_{eq} is much higher than bipolar because g_m is lower for FETs

2. i_{eq} is much lower than bipolar at low to moderate frequencies ($\omega C_{gs} \ll 1$) since $I_G \ll I_B$

Note: MOSFET $I_G = 0 \Rightarrow i_{eq} \approx 0$ at low to mod. freq.

$\Rightarrow$ Use FET when Input has high Source Impedance

Compare: equivalent noise sources of BJT

$$\overline{V_{eq}^2} = 4kT r_b \Delta f + 2kT \frac{1}{g_m} \Delta f$$

$$\overline{i_{eq}^2} = 2q I_B \Delta f + k_f \frac{I_B^2}{f} \Delta f + 2q I_C \frac{\Delta f}{|\beta(j\omega)|^2}$$

where $\beta(j\omega) = \frac{g_m r_\pi}{(1 + j\omega r_\pi C_\pi)}$ and $g_m = I_C \frac{q}{kT}$

Note: at low frequencies:

$$\begin{aligned} \overline{i_{eq}^2} &\approx \overline{i_b^2} \\ \overline{V_{eq}^2} &\approx \overline{V_b^2} + \frac{\overline{i_c^2}}{g_m^2} \end{aligned} \quad \begin{array}{l} \text{independent} \\ \text{sources} \end{array}$$

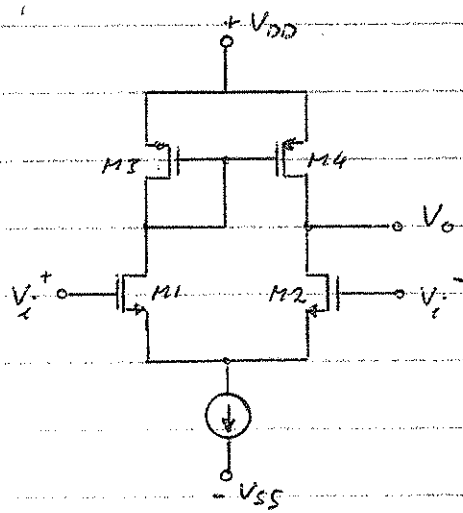
at high frequencies:

$$\begin{aligned} \overline{i_{eq}^2} &\approx \overline{i_b^2} + \frac{\overline{i_c^2}}{|\beta(j\omega)|^2} \\ \overline{V_{eq}^2} &\approx \overline{V_b^2} + \frac{\overline{i_c^2}}{g_m^2} \end{aligned} \quad \begin{array}{l} \text{dependent} \\ \text{sources} \end{array}$$

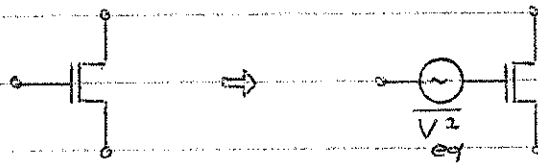
$$\overline{i_b^2} = 2q I_B \Delta f + k_f \frac{I_B^2}{f} \Delta f$$

$$\overline{i_c^2} = 2q I_C \Delta f = 2kT g_m \Delta f$$

Example ② Differential Input stage of CMOS Opamp



1. replace circuit elements by noiseless elements and their equivalent noise sources.



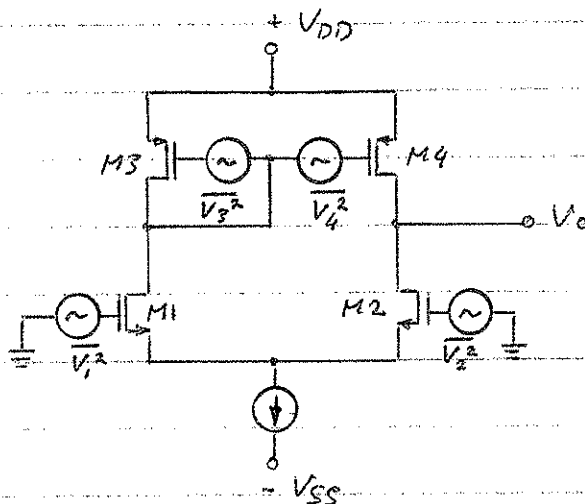
MOS

$$\overline{V_{eq}^2} = \left(\frac{8}{3} \frac{kT}{g_m} + K_1 \frac{I_D^2}{g_m^2} \right) \Delta f$$

$$\overline{V_{eq}^2} = \omega^2 C_{gs}^2 \overline{V_{eq}^2} \approx 0$$

$\frac{K}{WLC_{ox}f}$

2. Apply a small signal analysis to the circuit with the equivalent noise models and solve for the output noise power.



output noise power (assume $\overline{V_1^2} = \overline{V_2^2}$ and $\overline{V_3^2} = \overline{V_4^2}$)

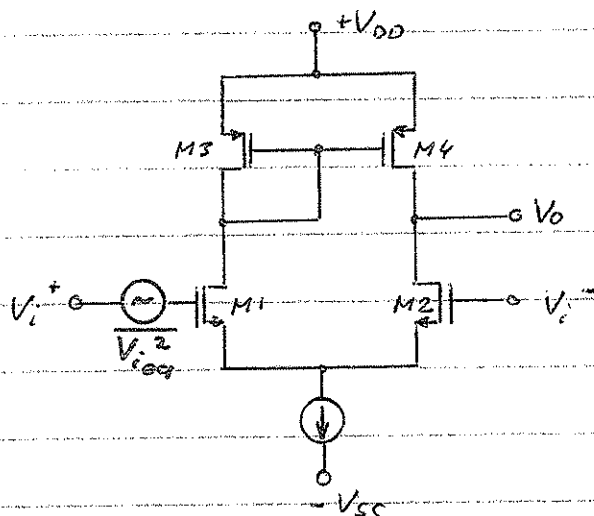
$$\overline{V_o^2} = \left(\frac{g_{m1}}{g_{o1} + g_{o3}} \right)^2 \left(2\overline{V_1^2} + 2 \left(\frac{g_{m3}}{g_{m1}} \right)^2 \overline{V_3^2} \right)$$

Note: $\left(\frac{g_{m1}}{g_{o1} + g_{o3}} \right) = \text{Gain of differential stage}$

3. calculate equivalent input noise source that produces the same output noise power

$$\overline{V_{ieq}^2} = \frac{\overline{V_o^2}}{A_d^2} \quad \text{where } A_d = \left(\frac{g_{m1}}{g_{o1} + g_{o3}} \right)$$

$$\Rightarrow \boxed{\overline{V_{ieq}^2} = 2\overline{V_1^2} + 2 \left(\frac{g_{m3}}{g_{m1}} \right)^2 \overline{V_3^2}}$$

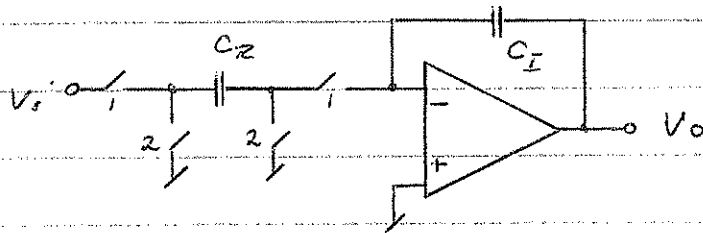


Note: $g_{m3} \ll g_{m1}$ (for high gain-bandwidth product)

Thus noise contribution of M1 and M2 is dominant

5. Sampled Noise (J. Fischer: Journ. SSC, pp. 742-752, Aug. 1982)

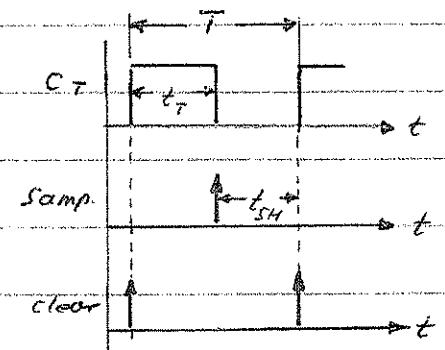
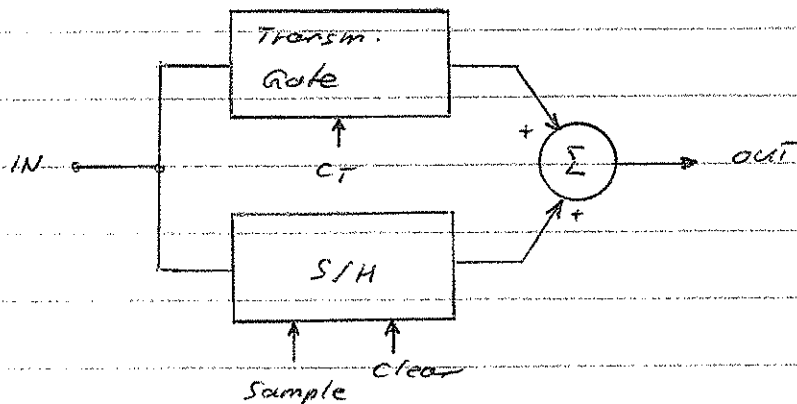
Example inverting SC integrator



What is noise response of this system?

This circuit performs a track and hold function (tracking during phase 1 and holding during phase 2)

Track and hold equivalent circuit



We assume input noise is white with equivalent bandwidth BW_n and power density n_n

note: equivalent noise bandwidth

$$\int_{-\infty}^{\infty} S_i(f) df = n_n \cdot BW_n$$

a) Sample-and-Hold Noise Model

If we assume an ideal S/H operation with holding time
 $T_H = \tau_{SH} \cdot T = \frac{\tau_{SH}}{f_s}$ ($\tau_{SH} = \frac{t_{SH}}{T}$), we obtain the following out-
 put power density

$$\left| \begin{array}{l} P_o(f) \leq P_n \tau_{SH}^2 \operatorname{sinc}^2\left(\frac{\tau_{SH} f}{f_s}\right) \end{array} \right| \quad \text{BW}_n \leq \frac{1}{2} f_s$$

$$\left| \begin{array}{l} P_o(f) \leq P_n 2 \frac{\text{BW}_n}{f_s} \tau_{SH}^2 \operatorname{sinc}^2\left(\frac{\tau_{SH} f}{f_s}\right) \end{array} \right| \quad \text{BW}_n \geq \frac{1}{2} f_s$$



Foldover effect due to undersampling of input noise

b) Track-and-Hold Noise Model

Since the Track-and-Hold operation occupies the entire
 sampling period, we can denote the tracking time

$T_T = \tau_T \cdot T$ by $(1 - \tau_{SH}) T$. The output power density is
 then equal to

$$\left| \begin{array}{l} P_o(f) \leq P_n \left[\underbrace{\tau_{SH}^2 \operatorname{sinc}^2\left(\frac{\tau_{SH} f}{f_s}\right)}_{\text{S/H}} + \underbrace{(1 - \tau_{SH})}_{\text{Track}} \right] \end{array} \right| \quad \text{BW}_n < \frac{1}{2} f_s$$

$$\left| \begin{array}{l} P_o(f) \leq P_n \left[2 \frac{\text{BW}_n}{f_s} \underbrace{\tau_{SH}^2 \operatorname{sinc}^2\left(\frac{\tau_{SH} f}{f_s}\right)}_{\text{S/H}} + \underbrace{(1 - \tau_{SH})}_{\text{Track}} \right] \end{array} \right| \quad \text{BW}_n \geq \frac{1}{2} f_s$$

Examples: a) $\tau_{SH} = 0$ (fully tracking $\rightarrow$ no S/H term)

$$\underline{\eta_o(f) = \eta_n} \quad \forall f$$

b) $\tau_{SH} = 1$ (ideal S/H $\rightarrow$ no tracking term)

$$\left| \begin{array}{l} \eta_o(f) \leq \eta_n \operatorname{sinc}^2\left(\frac{f}{f_s}\right) \quad | \quad BW_n < \frac{1}{2} f_s \\ \eta_o(f) \leq \eta_n 2 \frac{BW_n}{f_s} \operatorname{sinc}^2\left(\frac{f}{f_s}\right) \quad | \quad BW_n \geq \frac{1}{2} f_s \end{array} \right|$$

Output noise spectrum exhibits familiar
 $\operatorname{sinc}^2 x$ envelope

c) $\tau_{SH} = \frac{1}{2}$

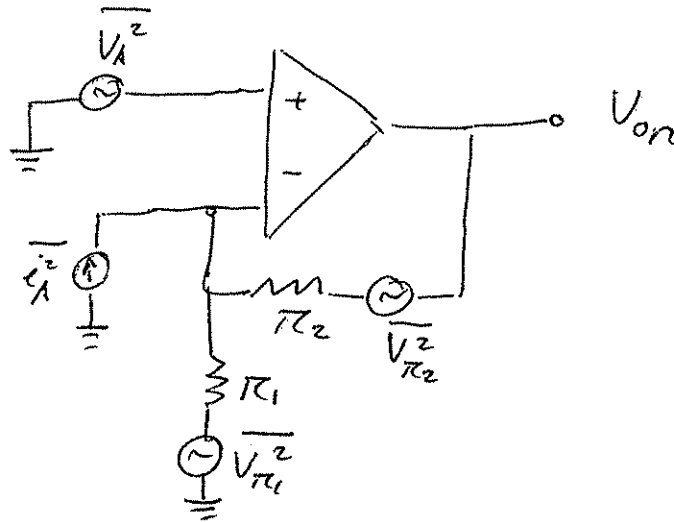
$$\left| \begin{array}{l} \eta_o(f) \leq \eta_n \frac{1}{2} \left[\frac{1}{2} \operatorname{sinc}^2\left(\frac{f}{2f_s}\right) + 1 \right] \quad | \quad BW_n < \frac{1}{2} f_s \\ \eta_o(f) \leq \eta_n \frac{1}{2} \left[\frac{BW_n}{f_s} \operatorname{sinc}^2\left(\frac{f}{2f_s}\right) + 1 \right] \quad | \quad BW_n \geq \frac{1}{2} f_s \end{array} \right|$$

In case of undersampled noise ($f_s \ll BW_n$) the low frequency noise is dominated by the S/H term ($\eta_o(f \rightarrow 0) \approx \frac{1}{2} \eta_n \frac{BW_n}{f_s}$) while the transmission gate term sets the high-frequency noise floor ($\eta_o(f \rightarrow \infty) = \frac{1}{2} \eta_n$)

Concept of Equivalent Input Noise

Example Noninverting amplifier

Equivalent circuit for Noise Analysis



$$\| V_{Op}^2 = V_A^2 \left(1 + \frac{R_2}{R_1}\right)^2 + i_A^2 R_2^2 + V_{R_1}^2 \frac{R_2^2}{R_1^2} + V_{R_2}^2 \|$$

where $\left| V_A^2 \approx 4kT \frac{2}{5} \frac{1}{f_{min}} + K_n \frac{1}{(W \cdot L C_{ox})_in} f \right|$

Amp. input pair

$$\left| i_A^2 \approx V_A^2 \omega^2 C_{gsin}^2 \right|$$

$$\left| V_{R_1}^2 = 4kT R_1 \right|$$

$$\left| \overline{V_{ieq}^2} = \frac{V_{on}^2}{A_{v_{in}}^2} = \overline{V_A^2} + \overline{V_A^2} \frac{R_2^2}{(1+R_2/R_1)^2} + 4kT \frac{R_2}{(1+R_2/R_1)} \right|$$

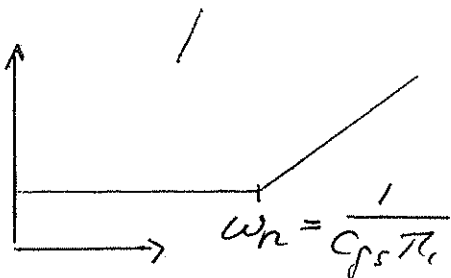
Inserting the actual amplifier noise sources yields:

$$\left\| \overline{V_{ieq}^2} \approx \overline{V_A^2} \left[1 + \frac{\omega^2 C_{fs}^2 R_2^2}{(1+R_2/R_1)^2} \right] + 4kT R_2 \frac{1}{(1+R_2/R_1)} \right\|$$

Opamp Contrib. External Res.

If $R_2 \gg R_1$

$$\left\| \overline{V_{ieq}^2} \approx \overline{V_A^2} \left[1 + \omega^2 C_{fs}^2 R_1^2 \right] + 4kT R_1 \right\|$$



e.g. $C_{fs} = 100 \text{ fF}$

$R_1 = 1 \text{ k}\Omega$

$\therefore \omega_n = 2\pi \cdot 1.6 \text{ GHz}$

$$\therefore \left\| \overline{V_{ieq}^2} \approx \overline{V_A^2} + 4kT R_1 \right\|$$

Note: Opamp gain roll-off prevents high-frequency noise increase

Total Noise Power

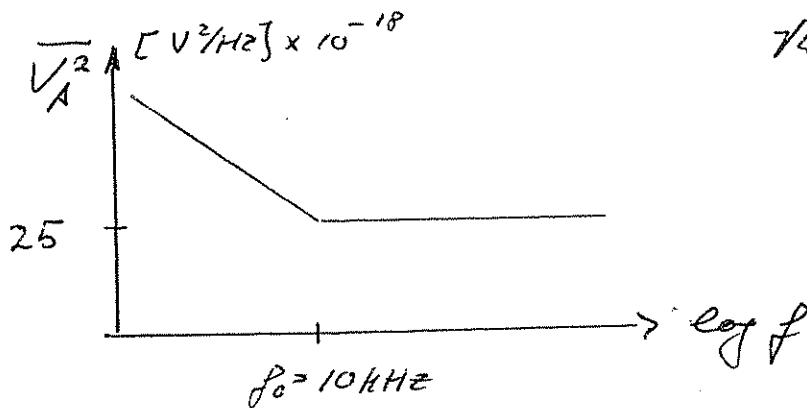
Example Noninverting amplifier

$$|\overline{V_{ieq}}^2 \approx \overline{V_A}^2 + 4kT\pi_1|$$

$$\pi_1 = 1k\Omega$$

$$4kT\pi_1 = 16.6 \times 10^{-18} \frac{V^2}{Hz}$$

$$\sqrt{4kT\pi_1} = 4.07 \frac{nV}{\sqrt{Hz}}$$



Question: What is the total noise power in the frequency band from 10Hz to 100kHz?

$$V_{niTot}^2 = \int_{\pi_1}^{\pi_2} V_{ieq}^2(f) df$$

$$\pi_1 = 10Hz$$

$$\pi_2 = 10^5 Hz$$

$$= \int_{\pi_1}^{\pi_2} (25 + 16.6) \times 10^{-18} df + \int_{\pi_1}^{\pi_2} 25 \times 10^{-18} \frac{f_0}{f} df$$

$$V_{niTot}^2 \approx 41.6 \times 10^{-15} [V^2] + 25 \times 10^{-18} \cdot 4 \cdot \ln(10) [V^2]$$

$$\| V_{niTot}^2 \approx 41.6 \times 10^{-15} [V^2] + 23 \times 10^{-15} [V^2] \|$$

/
/

Thermal Contr.
1/f Contribution

$$\therefore \| V_{niTot} \approx 2.54 \mu V \|$$

Low Noise CMOS Opamp

Design Guidelines

A) 1/f Noise

$$\left| \overline{V_{R_{N1R_i}}^2} \propto \frac{1}{\gamma(W/L)_{in}} \left[1 + \mu_r \sqrt{\frac{(W/L)_{ld}}{(W/L)_{in}}} \right] \frac{1}{\sqrt{I_{diff}}} \right| \quad (1)$$

B) 1/f Noise

$$\left| \overline{V_{N1f_i}}^2 \propto \frac{1}{(W \cdot L)_{in}} \left[1 + \mu_r \frac{L_{in}^2}{L_{ld}^2} \right] \right| \quad (2)$$

where $\mu_r = \begin{cases} \frac{k_p \mu_p}{k_n \mu_n} & \text{n-channel input stage} \\ \frac{k_n \mu_n}{k_p \mu_p} & \text{p-channel input stage} \end{cases}$

n-channel input $\mu_{r_{si}} \approx 0.15 - 0.35$
 p-channel input $\mu_{r_{si}} \approx 3 - 7$

To keep 1/f contribution of load stage within reason,
 one should select $\left| L_{ld} > \sqrt{2\mu_r} L_{in} \right|$

e.g. n-channel input: $L_{ld} > 0.7 L_{in}$

p-channel input: $L_{ld} > 3.2 L_{in}$